UNITED STATES PATENT AT PERSONNEL STATES PATENT AT PROPRIES PATENT AT PATEN	ND TRADEMARK OFFICE	UNITED STATES DEPAR United States Patent and Address: COMMISSIONER F P.O. Box 1450 Alexandria, Virginia 223 www.uspto.gov	Trademark Office OR PATENTS
APPLICATION NO. FILING PATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/700,429 11/03/2003	Glenn Joseph Leedy	ELM-1 Cont. 10	5639
1473 7590 06/11/2007		EXAMINER RAO, SHRINIVAS H	
FISH & NEAVE IP GROUP ROPES & GRAY LLP			
1211 AVENUE OF THE AMERICAS NEW YORK, NY 10036-8704		ART UNIT	PAPER NUMBER
		2814	
•		MAIL DATE	DELIVERY MODE
		06/11/2007	PAPER

The time-period for reply, if any,-is-set-in-the-attached communication.

OF					
01 40	Application No.	Applicant(s)			
JUN Office Action Summary	10/700,429	LEEDY, GLENN JOSEPH			
Office Action Summary	Examiner	Art Unit			
	Steven H. Rao	2814			
Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY					
WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period with period for reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	TE OF THIS COMMUNICATION 6(a). In no event, however, may a reply be timil apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	N. the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
1)⊠ Responsive to communication(s) filed on <u>05 April 2007</u> .					
2a)⊠ This action is FINAL . 2b)□ This	☐ This action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4)⊠ Claim(s) <u>77-272</u> is/are pending in the application.					
4a) Of the above claim(s) 77-109,211-222 and 254-272 is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.					
6) Claim(s) <u>109-210 & 223-258</u> is/are rejected.					
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or	election requirement				
o/ ordinite/ are casjest to resultation and or	ologion requirement				
Application Papers					
9) The specification is objected to by the Examiner					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
11) The oath or declaration is objected to by the Exa					
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a) ☐ All b) ☐ Some * c) ☐ None of:					
1. Certified copies of the priority documents have been received.					
2. Certified copies of the priority documents have been received in Application No					
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).					
* See the attached detailed Office action for a list of the certified copies not received.					
	, , , , , , , , , , , , , , , , , , , ,	·			
Attachment(s) 1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)			
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)					
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	6) Other:	atent Application			
S. Retent and Trademark Office					

Art Unit: 2814

Response to Amendment

Applicants' amendment filed on March 22, 2007 has been entered and forwarded to the Examiner on April 05, 2007.

Therefore claims 109,122,135,163,179 and 195 as amended by the amendment and claims 110-121,123-134,136-162,164-178,180-194,196-210,and 223-258 as previously recited are currently pending in the Application.

Claims 1-76 have been previously cancelled. Claims 77-108, 211-222, and 259-272 are currently withdrawn from consideration.

Information Disclosure Statement

No further IDSs after the one filed on January 11, 2006 has been filed in this application.

Claim Rejections . 35 USC Section 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action.

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the

Art Unit: 2814

invention was made to a person having ordinary skill in the art to which said subject matter pertains

Patentability shall not be negatived by the manner in which the invention was made.

Claims 109-201 and 223-258 are rejected under 35 U.S.C. 103 as being unpatentable over Shimoji (U.S. Patent No. 5,420,458, herein after Shimoji) and Mattox (U.S. Patent No. 4,825,277, herein after Mattox).

With respect to claim 109, 122,163, 179 and 195, Shimoji describes a method of making an integrated circuit including the steps of: Forming a thin substrate (Shimoji, Fig. 3 A # 21, col. 3 line 48) with uniform thickness (Shimoji col. 2 lines 45-46) and forming on the substrate circuitry including active devices (Shimoji, Fig. 2 C # 51, 52, col. 3 lines 65-68);

Shimoji does not specifically describe the integrated circuit is substantially flexible while retaining its Structural integrity.

However. Mattox in col. 9 lines 1-13 describes the integrated circuit is ;substantially flexible while retaining its structural integrity to the semiconductor surface.

Therefore it would have been obvious to a person of ordinary skill in the art at the time of the invention to use the Mattox's stress controlled dielectric membrane instead of Shimoji's to dielectric layer form devices having

Art Unit: 2814

controlled stress relative to the semiconductor surface (Mattox col. 2 lines 5-10).

And removing a major portion of the semiconductor substrate while retaining the structural integrity (Shimoji Fig. 6 B # 8, col. 4 lines 50-57).

With respect to dependent claims110- 114, 123-127, 136-140, 147-150, 153-155, 159-160,164-166,174-176,180-182,190-192, 196-198 and 206-209, wherein the thin substrate is formed prior to forming circuitry (Shimoji, Fig. 3 A # 21, col. 3 line 48)., after forming said circuitry, (Shimoji fig. 4, col. 4 lines 5-15) an elastic dielectric layer overlying the active devices. (Shimoji, Fig. 2 C # 51, 52, col. 3 lines 65-68, Mattox); deposition of elastic dielectric film by RF, CVD, PECVD (Mattox, also all well known in the art methods of deposition and also Shimoji col. 4 lines 15-20).

With respect to dependent claims 115, 128, 141,151,156,161,167,177, 183-,, 193, 8 2 and 199, wherein the dielectric membrane is caused to have a stress of 8 x 10 dynes/cm or less. (See Mattox claim 9)

Mattox does not specifically mention a surface stress of 8 X 10 8 dynes/cm 2. However Mattox in col. 7 lines 45-52 describes the stress range to be between -1 to 5 x 10 8 g dynes/cms to 1 x 109 to form devices having controlled stress relative to the semiconductor surface.

Therefore it would have been obvious to a person of ordinary skill in the art at

Art Unit: 2814

the time of the invention to use the stress range 8 X 10 8 dynes/cm 2 instead of Mattox's 9 dynes/cms to 1 X 10 9 dynes/cm previously described overlapping range of 1 to 5 X 10 y 2 to form devices having controlled stress relative to the semiconductor surface (Mattox col. 2 lines 5-10).

With respect to claims 116, 119-120, 129, 132-133, 142, 145-146, 149, 157-159 162-164-165, 168, 171-172,174, 178, 184,187-188, 194, 196-197,200, 203-204, 206-207 and 210 wherein the stress is tensile (Mattox abstract line 8, etc., silicon or dielectric substrate (Shmioji see rejection of clam 110 above);

With respect to remaining claims including claims117-118, 130-131,134-135,141,143-144,145,156,167-170,177,183,185-186,193,195,199 201-202,206-209 and Claims 121,147 and 205 wherein the integrated circuit can be thinned to 50 microns. (Mattox col. 4 lines'15-23), and 205 wherein the dielectric layer is formed of inorganic material of an oxide of silicon, a nitride of silicon (Shmioji, silicon dioxide/nitride) or organic (Shmioji or well Know - e.g. TOES).

Response to Arguments

Art Unit: 2814

Applicant's arguments filed on Jan. 20, 2006 have been fully considered but they are not persuasive, for the following reasons:

Applicants' arguments with regard to claims 179-194 and 247-252 are based impermissible piece meal analysis of why Shimoji or Mattox individually and not as combined allegedly do not teach/describe the recited "wherein the integrated circuit is elastic while retaining its structural integrity" is not persuasive.

In response to Applicants' piece meal analysis of the references, it has been held that one cannot show non-obviousness by attacking references individually where, as here, the rejections are based on combinations of references.

Applicants' contention that Shimoji (and Mattox) det teach/describe "
providing a thin substrate with a uniform thickness" is not persuasive for
reasons set out in the rejection above namely (Shimoji, Fig. 3 A # 21, col.
3 line 48) with uniform thickness (Shimoji col. 2 lines 45-46).

Applicants' contention that Mattox in col. 9 lines 1-13 does not show or suggest that the integrated circuit is elastic for reasons set out in detail in the previous response (pages 6-7) and incorporated here by reference for the sake of brevity.

Art Unit: 2814

Applicants' essentially repeat the same arguments with respect to claim dependent claims 110-121,148-152,222-228 dependent upon claim 109; claims 123-134, 153-157 and 229-234 dependent upon claim 122; claims 136-147,158-162 and 235-240 dependent upon claim 135; claims 164-178 and 241-246 dependent upon claim 163 and claims 196-210 and 253-258 dependent upon claim 195, namely the applied references to show/describe "wherein the integrated circuit is elastic while retaining its structural integrity" is not persuasive for reasons set out above and incorporated here by reference for sake of brevity.

Therefore all of applicants' arguments are not found to be persuasive and all the pending claims are rejected.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

Art Unit: 2814

the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Steven H. Rao whose telephone number is (571) 272-1718. The examiner can normally be reached on 8.30-5.30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on 571-272-1714. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Steven H. Rao

Patent Examiner

May 31, 2007

Organization 116 States Patent and Trademark Office

OFFICIAL BUSINESS PENALTY FOR PRIVATE USE, \$300

CO OTHER

AN EQUAL OPPORTUNITY EMPLOYER

USPTO MAIL CENTER RECEIVED JUN 2 1 2007.



P.O. Box 1450

Alexandria, VA 22313-1450 If Undeliverable Return in Ten Days